

Notice of References Cited	Application/Control No. 10/524,610		Applicant(s)/Patent Under Reexamination LAERMER ET AL.	
	Examiner Hoang-Quan T. Ho		Art Unit 2818	Page 1 of 1

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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